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Citation: *J. Appl. Phys.* **111**, 043509 (2012); doi: 10.1063/1.3684981

View online: <http://dx.doi.org/10.1063/1.3684981>

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Effect of interface alloying and band-alignment on the Auger recombination of heteronanocrystals

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(Received 9 November 2011; accepted 10 January 2012; published online 21 February 2012)

We report a numerical study of the effect of interface alloying and band alignment on the Auger recombination processes of core/shell nanocrystals. Smooth interfaces are found to suppress Auger recombination, the strength of the suppression being very sensitive to the core size. The use of type-II structures constitutes an additional source of suppression, especially when the shell confines electrons rather than holes. We show that “magic” sizes leading to negligible Auger recombination [Cragg and Efros, *Nano Letters* **10**, 313 (2010)] should be easier to realize experimentally in nanocrystals with extended interface alloying and wide bandgap. © 2012 American Institute of Physics. [doi:10.1063/1.3684981]

I. INTRODUCTION

There is current interest in minimizing Auger recombination (AR) processes in semiconductor nanocrystals (NCs). This is because such processes are considered to be responsible for the undesired blinking of NCs, which hinders their use in optical applications.¹ When an electron-hole pair is generated in a NC by absorption of light, there is a possibility that one of the two carriers becomes trapped at the surface. When the next electron-hole pair is created, it combines with the remaining carrier. If the remaining carrier is a hole, the NC now contains a positive trion (as in Fig. 1(a)). If it is an electron, it contains a negative trion (as in Fig. 1(b)). At this point, there is a competition between radiative electron-hole recombination and non-radiative Auger recombination, by which the energy of the recombining electron-hole pair is transferred to the extra carrier—as shown in Figs. 1(a) and 1(b). The excess carrier then moves into a highly excited (typically unbound) state and rapidly loses kinetic energy to heat. For optical emission to be free from blinking, the AR process must be slower than the radiative recombination one.

Two promising techniques in slowing down AR processes have been developed in the last years: (i) the use of hetero-NCs with radially graded composition² and (ii) the use of hetero-NCs with quasi-type-II or type-II band alignment.^{3–9} Theoretical understanding of the AR suppression in (i) was provided by Cragg and Efros.¹⁰ They showed that the smooth confinement potential resulting from the graded composition removes high-frequency Fourier components of the electron and hole wave functions, which in turn reduces AR rates. Theoretical understanding of the AR suppression in (ii) was provided by us in Ref. 11, where we showed that it is originated in the removal of high-frequency components of the carrier that penetrates into the shell.

In this work, we extend Refs. 10 and 11 by performing a systematic study of the influence of smooth confinement potentials and band alignment on the AR rates of hetero-NCs. We consider not only AR processes involving excess holes

(Fig. 1(a)), but also excess electrons (Fig. 1(b)). We find that, as noted in Ref. 10, the softer the confinement potential, the slower the AR. However, the magnitude of the AR suppression strongly depends on the core sizes, with order-of-magnitude differences. A similar behavior is observed when varying the core-shell band-offset. In general, moving from type-I to type-II hetero-NC translates into slower AR rates, but the actual value is very sensitive to the NC dimensions. The decrease of the AR rate is particularly pronounced when the carrier confined in the shell is the electron instead of the hole. Last, we show that the narrow ranges of (“magic”) NC sizes leading to almost complete suppression of AR reported in Refs. 10 and 16 become wider in NCs with smooth potential or wide bandgap.

II. THEORY

The model we use is essentially that employed in Ref. 10, except that here the wave functions are calculated numerically for arbitrary potential shapes. Thus, in our calculations, we describe electrons and holes with a one-dimensional, two-band Kane Hamiltonian,¹²

$$H = \begin{pmatrix} -\frac{p^2}{2m_e} + V_c(x) + E_g/2 & Kp \\ Kp & \frac{p^2}{2m_h} - V_v(x) - E_g/2 \end{pmatrix}, \quad (1)$$

where $p = -i\hbar\partial/\partial x$ is the momentum operator and $m_e(h)$ is the effective mass of the electron (hole), disregarding the influence of the valence (conduction) band, hereafter VB (CB). E_g is the energy gap, as defined in Fig. 1(c), K is the Kane matrix element, and $V_{c(v)}(x)$ is the CB (VB) confinement potential. The height of $V_{c(v)}(x)$ is given by the core/shell band-offset, and the shape is depicted in Fig. 1(c). Note that, at the core-shell interface, $V_{c(v)}(x)$ has a cosine-like profile of width w , which accounts for interfacial diffusion. Varying w , we can monitor the evolution from abrupt interfaces ($w = 1 \text{ \AA}$) to alloyed interfaces spread over several monolayers (w tens of \AA), accounting for either spontaneous interfacial diffusion⁹ or intentionally graded

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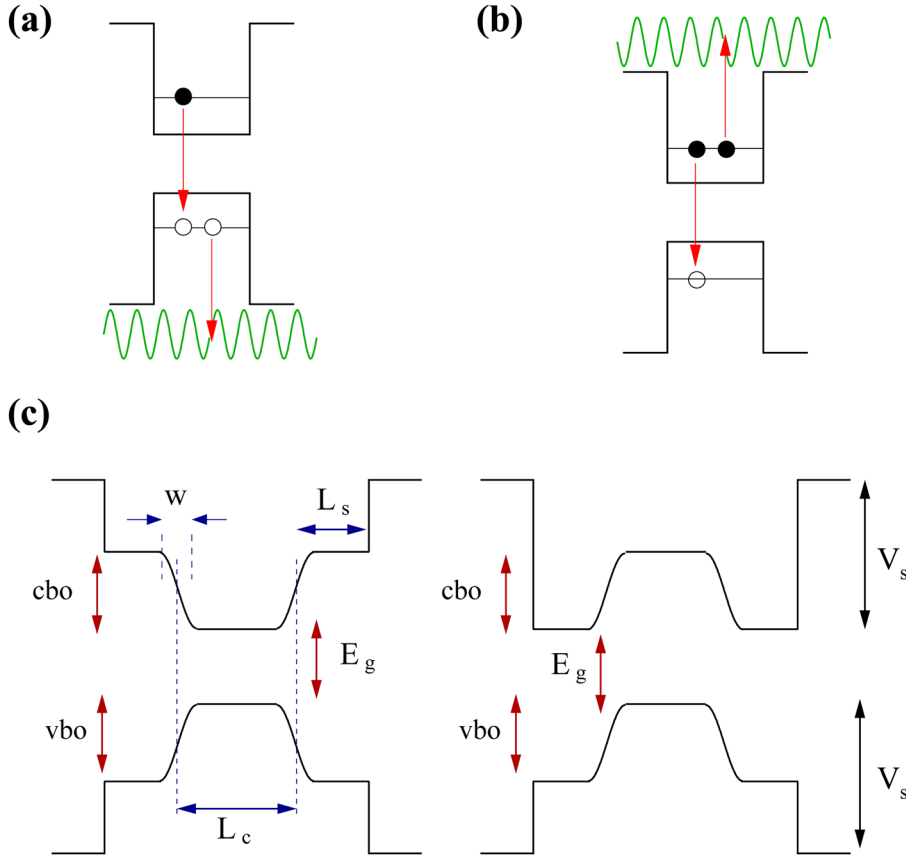


FIG. 1. (Color online) Schematic of the Auger process under study, assuming the NC contains a positive (a) and negative (b) trion. (c) Confinement potential profile used for type-I (left) and type-II NCs (right).

composition.² Equation (1) is integrated numerically using a finite differences scheme. The resulting electron and hole states have a mixture of CB and VB components,

$$\psi_i = \chi_i(x)u_c(x) + \eta_i(x)u_v(x), \quad (2)$$

with $i = e, h$. Here, χ and η (u_c and u_v) are the envelope (periodic) parts of the Bloch wave function corresponding to the CB and VB, respectively. For electrons, the CB component χ is by far dominant. The opposite holds for holes.

The AR rate is calculated using Fermi's golden rule,

$$\tau_A^{-1} = \frac{2\pi}{\hbar} |\langle i|V|f\rangle|^2 \rho(E_f) \delta(E_i - E_f). \quad (3)$$

Here, $V(r) = 1/(\epsilon(r + \Delta))$ is the Coulomb potential, with ϵ the dielectric constant, $r = |x_1 - x_2|$, and Δ a parameter introduced to avoid the Coulomb singularity. E_i and E_f are the energies of the initial and final states, respectively.

To proceed further, we consider the NC are in the strong confinement regime. Let us first assume the most relevant AR process is that illustrated in Fig. 1(a). This seems to be the case at least in CdSe/ZnS and CdZnSe/ZnSe NCs.^{2,13} The initial state, $|i\rangle$, is then defined by two holes in the lowest orbital,

$$|i\rangle = \psi_h^0(x_1)\psi_h^0(x_2) \frac{1}{\sqrt{2}}(\alpha(1)\beta(2) - \beta(1)\alpha(2)), \quad (4)$$

with $\alpha(\beta)$ standing for spin up (down) projections. The final state, $|f\rangle$, corresponds to one hole promoting to the CB and the other excited into the continuum,

$$|f\rangle = \frac{1}{\sqrt{2}}(\psi_e^0(x_1) * \psi_h^{ex}(x_2) + \psi_h^{ex}(x_1)\psi_e^0(x_2)) \frac{1}{\sqrt{2}}(\alpha(1)\beta(2) - \beta(1)\alpha(2)). \quad (5)$$

The excited, unbound hole state is taken as $\psi_h^{ex}(x) = \sqrt{\frac{1}{L}}e^{ikx}u_v$, i.e., a free electron plane wave with negligible component in the CB. L is the length of the computational box. The momentum k is determined by energy conservation, $k = \sqrt{2m_0(E_e^0 + 2E_h^0 + E_g)/\hbar}$, where m_0 is the free electron mass, while E_e^0 and E_h^0 are the single-particle electron and hole energies defined with respect to the CB and VB edges, respectively. $\rho(E_f)$ is the density of states of $|f\rangle$, which can be approximated by that of the hole in the continuum (computational box), $\rho(E_f) \approx L/\hbar\pi\sqrt{m_0/2E_h^{ex}}$, where $E_h^{ex} = (k^2/2m_0 - V_s)$ is the single-particle energy of the plane wave subtracting the confinement potential of the outer shell. Note that L in $\rho(E_f)$ cancels the L factor arising from the plane wave normalization constants in $|\langle i|V|f\rangle|^2$.

Because $\psi_h^{ex}(x)$ has no CB component, the Coulomb matrix element in Eq. (3) is given by

$$\langle i|V|f\rangle = \sqrt{2}(\langle \chi_h \eta_h | V | \chi_e e^{ikx_2} \rangle + \langle \eta_h \eta_h | V | \eta_e e^{ikx_2} \rangle). \quad (6)$$

Equation (6) shows that Auger processes require electron-hole Coulomb coupling involving either the CB component of the hole (χ_h) or the VB component of the electron (η_e). In other words, conduction-valence band coupling is necessary

for such processes. The two-band Kane Hamiltonian we use, Eq. (1), is the simplest model including this factor.

For computational performance and physical insight, it is convenient to rewrite the above integrals in the Fourier space. For example,

$$\langle \chi_h \eta_h | V | \chi_e e^{ikx_2} \rangle = \frac{1}{2\pi} \int_{-\infty}^{\infty} dq \hat{V}(q) \hat{\chi}(q) \hat{\eta}(q), \quad (7)$$

where $\hat{V}(q) = (e^{-iq\Delta} E_1(-iq\Delta) + e^{iq\Delta} E_1(iq\Delta)) / \epsilon$ is the Fourier transform of $V(r)$, with $E_1(x) = \int_x^{\infty} e^{-t}/t dt$ as the exponential integral.¹⁴ $\hat{\chi}(q) = \int dx_1 \chi_h(x_1) * \chi_e(x_1) e^{iqx_1}$ is the Fourier transform of the CB components and $\hat{\eta}(q) = \int dx_2 \eta_h(x_2) * e^{(k-q)x_2}$ that of the VB components.

An analogous development can be carried out for the case of Fig. 1(b), where the relevant AR process is that involving a negative trion. In such a case,

$$\langle i | V | f \rangle = \sqrt{2} (\langle \eta_e \chi_e | V | \eta_h e^{ikx_2} \rangle + \langle \chi_e \chi_e | V | \chi_h e^{ikx_2} \rangle). \quad (8)$$

For the simulations, we take material parameters close to those of typical II-VI NCs: $m_e = 0.15m_0$, $m_h = 0.6m_0$, $E_g = 1.5$ eV, $K = (21 \text{ eV}/2m_0)^{1/2}$, $\epsilon = 6$, and $\Delta = 10^{-2}$ Å. The CB offset (cbo) and VB offset (vbo) at the shell is 0.5 eV, unless otherwise stated. A high potential barrier, $V_s = 4$ eV, is set at the external medium. Even though the exact onset energy of the continuum is not well known, taking different values (of the order of eV) changes the Auger rates by a few ns only.

III. RESULTS AND DISCUSSION

A. Effect of interface alloying

We start by studying a type-I core/shell NC, where electrons and holes are well confined in the core, surrounded by a $L_s = 20$ Å shell acting as a barrier. We consider AR involves an excess hole (Fig. 1(a) scheme) and model the influence of diffusion around the interface by shaping the confining potential from abrupt ($w = 1$ Å) to smooth (diffusion spreading over $w = 30$ Å) for different core sizes. The resulting AR rates are plotted in Fig. 2(a). As expected from simple “volume” scaling,^{10,15} in general, the bigger the core, the slower the AR rate. In addition, for a given w , one can see that increasing the core size leads to periodic valleys, where AR is strongly suppressed (e.g., at $L_c \approx 20, 30$, and 40 Å for $w = 1$ Å). These “magic sizes” were first predicted by Efros and co-workers.¹⁶ They are originated in destructive quantum interferences between the initial and final states of the Auger scattering and should be detectable at low temperature and pumping power.¹⁰ We now pay attention to the influence of interface smoothness. In general, softening the interface potential reduces the AR by up to two orders of magnitude.^{10,16} However, this trend is neither universal nor monotonic, because, as can be seen in Fig. 2(a), softening the potential also changes the position of the suppression valleys. This point is exemplified in Fig. 2(b), which illustrates the vertical cross-sections highlighted in Fig. 2(a) with dashed lines. For some core sizes ($L_c = 25$ Å), there is a strong decrease of τ_A^{-1} with w . For others, which are initially

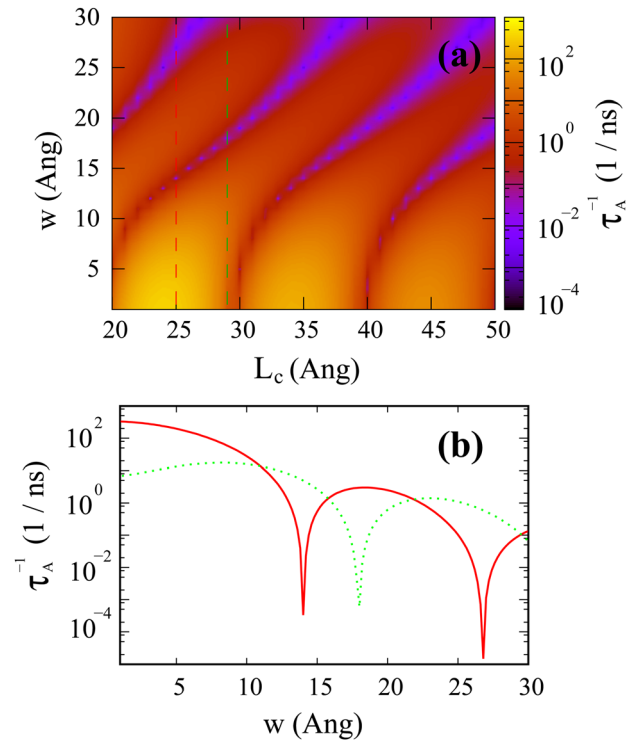


FIG. 2. (Color online) (a) Contour plot of the AR rate as a function of core size and interfacial thickness in type-I NCs. (b) Vertical cross-sections at $L_c = 25$ Å (solid line) and $L_c = 29$ Å (dotted line). The AR process considered is that involving an excess hole.

in a valley of AR ($L_c = 29$ Å), softening the potential provides no benefit up to large values of w ($w > 12$ Å). The shift in the position of the suppression valleys with increasing w is due to the decrease of the effective NC size as the shell material diffuses into the core. Interestingly, while the valleys are very narrow for $w = 1$ Å ($\Delta L_c \sim 1$ Å), they become wider for $w = 30$ Å ($\Delta L_c \sim 4$ Å). This should facilitate the experimental observation of these minima, since the most precise growth techniques rely on monolayer deposition (~ 4 Å each monolayer in typical II-VI NCs).

Next, we provide some insight into the conditions favoring the appearance of magic sizes. In the reciprocal space, the minima occur when there is a near cancellation of Eq. (7). For illustration purposes, we consider a simple core-only NC with interface thickness $w = 1$ Å. The inset in Fig. 3 shows the appearance of magic sizes with increasing L . The main panel shows the Fourier spectrum of $\hat{\chi}(q)$ and $\hat{\eta}(q)$ corresponding to the magic size at $L_c = 29.5$ Å ($\hat{V}(q)$ is a slowly varying function with secondary influence on the integral value (Ref. 11)). Note that, while $\hat{\chi}(q)$ is centered at $q = 0$, $\hat{\eta}(q)$ is centered at $q = k$. If the k value is such that one of the periodic zeros of $\hat{\eta}(q)$ coincides with the nearby maximum of $\hat{\chi}(q)$, as in the figure—see vertical arrow— $\hat{\eta}(q)$ and $\hat{\chi}(q)$ are in anti-phase and the AR minimum is obtained. The NC sizes which lead to this situation can be approximated with a simple model. Let the potential in Eq. (1) be that of a square well with infinite walls and width L_c . If we include interband coupling by perturbation theory on the basis of the two lowest CB and VB states, the ground state wave functions are

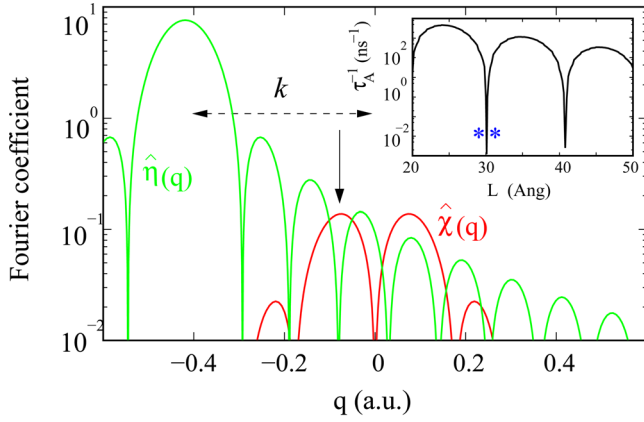


FIG. 3. (Color online) Fourier transforms of the CB and VB terms in the Auger matrix element of Eq. (7). The calculation corresponds to the AR minimum marked with asterisks in the inset.

$$\psi_e^0 = a_e \cos\left(\frac{\pi x}{L_c}\right) u_c + b_e \sin\left(\frac{2\pi x}{L_c}\right) u_v, \quad (9)$$

$$\psi_h^0 = a_h \sin\left(\frac{2\pi x}{L_c}\right) u_c + b_h \cos\left(\frac{\pi x}{L_c}\right) u_v, \quad (10)$$

where a and b are constants. The Fourier transform of the VB components, $\hat{\eta}(q)$, has zeros at $q_0 = k \pm \frac{\pi}{L_c} (2n + 1)$, with $n = 1, 2, 3, \dots$. On the other hand, the Fourier transform of the CB components, $\hat{\chi}(q)$, has the first local maximum at $q_M L_c \approx -2\pi$. We can then force $q_M = q_0$, obtaining $k = -\pi (2 \pm (2n + 1))/L_c$. Since $k = -\sqrt{2m_0(E_e^0 + 2E_h^0 + E_g)}/\hbar$, using particle-in-the-box energies, we get

$$\sqrt{m_0 \left(\frac{\pi^2}{m_e L_c^2} + 2 \frac{\pi^2}{m_h L_c^2} + \frac{2E_g}{\hbar^2} \right)} = \frac{\pi}{L_c} (2 \pm (2n + 1)). \quad (11)$$

Isolating L_c in the above expression leads to

$$L_c = \frac{\hbar \pi \sqrt{j^2 - (m_0/m_e + 2m_0/m_h)}}{\sqrt{2E_g m_0}}, \quad (12)$$

where $j = (2 \pm (2n + 1))$ is an odd number referring to an anti-phase condition. For the system in the Fig. 3 inset, increasing values of j in Eq. (12) predict “magic” NC sizes at $L_c = 19, 31, 42,$ and 53 \AA . These values are in close agreement with the numerical results. Equation (12) also reveals that wide gap materials are more prone to display AR minima.

So far, we have considered AR processes involving an excess hole. Very similar results are obtained if the process involves an excess electron instead. To illustrate this point, in Fig. 4, we reproduce Fig. 2(a), but now considering the negative trion process. In general, the AR are a few times slower, but the trends are the same and even the position of the AR minima are nearly the same. This implies that magic sizes can suppress AR for either of the two processes.

B. Effect of band alignment

In this section, we study how the core/shell potential height influences the AR rates. CB and VB offsets are ini-

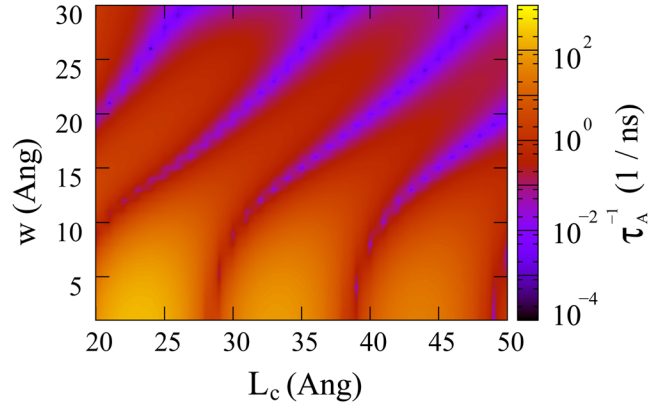


FIG. 4. (Color online) Same as Fig. 2(a), but for an excess-electron process.

tially set at 0.5 eV, then we lower the cbo—Fig. 5(a)—or the vbo—Fig. 5(b). One can see that lowering the offsets from 0.5 eV to 0.0 eV has a rather weak effect on τ_A^{-1} . However, moving to negative offsets (i.e., switching from type-I to type-II band alignment) brings about important modifications. Namely, (i) the position of the AR suppression valleys is shifted. This is due to the changes in the effective NC size seen by electrons and holes. (ii) The width of the suppression valleys increases, especially for negative cbo (Fig. 5(a)). (iii) Lowering cbo reduces τ_A^{-1} by orders of magnitude. This is in agreement with the experiments of Oron *et al.*,³ where using CdTe/CdSe NC—with the hole confined in the core and the electron in the shell—led to a strong decrease of the AR rate. Surprisingly, lowering vbo instead (Fig. 5(b)) barely reduces τ_A^{-1} . In other words, using CdSe/CdTe NCs would provide much less benefit.

The origin of the asymmetric behavior of electrons and holes in Fig. 5 can be ascribed to the different effective masses. To clarify this point, in Fig. 6, we compare the density charge of the dominant electron and hole wave function

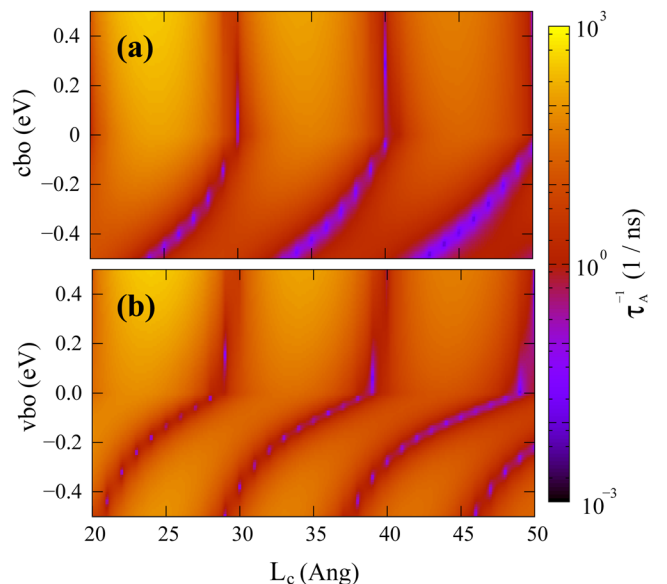


FIG. 5. (Color online) Contour plot of the AR rate as a function of core size and core/shell band-offset. (a) Variable cbo; (b) variable vbo. The shell thickness is $L_s = 20 \text{ \AA}$ and $w = 1 \text{ \AA}$.

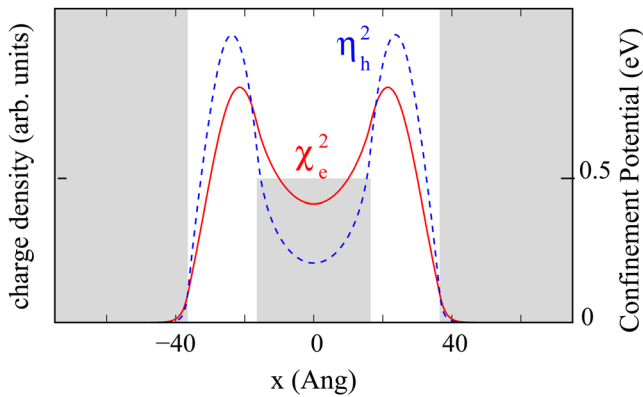


FIG. 6. (Color online) Density charge of the dominant electron and hole wave function components in a type-II NC where the carrier is confined in the shell. The gray area represents the confinement barrier. $L_c = 33 \text{ \AA}$ and $L_s = 20 \text{ \AA}$. Effect of vbo on the AR rate holds for processes involving an excess electron.

components in type-II NCs. Because of the lighter effective mass, the electron (χ_e^2) displays stronger tunneling across the core. The resulting wave function is smoother, which translates into less high-frequency Fourier components than the hole and, hence, slower AR.

We close by noting that, in three-dimensional systems, quantitative differences will probably arise from our estimates. Yet, the different role of cbo and vbo should persist, as the effective masses of the two carriers are still different. Also, we have checked that the weak effect of vbo on the AR rate holds for processes involving an excess electron.

IV. CONCLUSIONS

Using a two-band Kane Hamiltonian, we have studied how the interface potential shape and height influence the AR rates of heteronanocrystals. As previously noted,^{10,16} a smooth confinement potential—which may result from either spontaneous interfacial diffusion or intentionally graded composition—reduces the AR rate. However, the magnitude of this reduction strongly depends on the core size. This is due to the dependence of the “magic” sizes suppressing AR on the interface thickness. Indeed, the range of “magic” sizes increases with the interface thickness, which should facilitate

their experimental detection. Switching from type-I to type-II band-alignment further reduces the AR. For moderate band-offsets (fraction of eV), this effect is more pronounced when the shell hosts the electron (instead of the hole). This is because the stronger tunneling of electrons enables the formation of smooth wave functions. These results are valid for AR processes involving either an excess electron or an excess hole.

ACKNOWLEDGMENTS

Support from MCINN projects CTQ2008-03344 and CTQ2011-27324, UJI-Bancaixa projects P1-1A2009-03 and P1-1B2011-01, and the Ramon y Cajal program (JIC) is acknowledged.

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